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TOF-SIMS molecular depth profiling of polymers and organic materials using low energy atomic primary ions for sputtering

Mine, Nicolas

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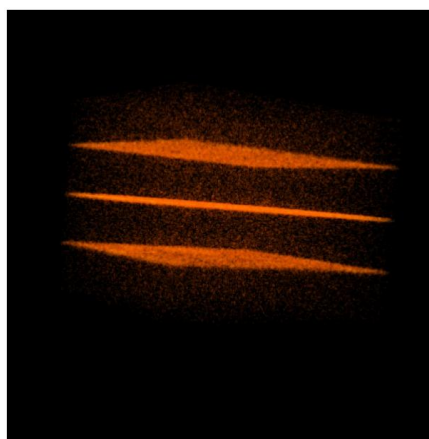
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ToF-SIMS molecular depth profiling of polymers and organic materials using low energy atomic primary ions for sputtering

(Profilage moléculaire de polymères et de matériaux organiques en ToF-SIMS à l'aide d'ions primaires atomiques de basse énergie pour l'érosion.)



Thèse présentée par
Nicolas Mine
en vue de l'obtention
du grade de Docteur en Sciences

Faculté des Sciences

Département de Physique
Centre de Recherche en Physique
de la Matière et du Rayonnement
(PMR)
Université de Namur

Composition du jury :

Dr. Tom Wirtz
Prof. Patrick Bertrand
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Prof. J.-J. Pireaux
Prof. L. Houssiau (promoteur)

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